

REMARKS

In view of the above amendments and following remarks, reconsideration and further examination are requested.

The specification and abstract have been reviewed and revised to make editorial changes thereto and generally improve the form thereof, and a substitute specification and abstract are provided. No new matter has been added by the substitute specification and abstract.

By the current Amendment, claims 1-43 have been canceled and claims 44-82 have been added. New claims 44-82 correspond to former claims 1-4, 7, 5, 6 and 8-39, respectively, and have been drafted taking into account the objections noted by the Examiner on page 2 of the Office Action, are believed to be free of the bases for these objections, and are otherwise believed to be in compliance with 35 U.S.C. § 112, second paragraph. Please note that in claim 2, “a surface” in line 2 provides antecedent basis for “the surface” in line 3.

Claims 1-39 were rejected under 35 U.S.C. § 102(e) as being anticipated by Gyoutoku et al. In reply to this rejection, provided herewith are verified English translations of priority documents JP 2002-315652, JP 2002-315654 and JP 2002-315653. Please note that JP 2002-315653 supports claims 44-53, JP 2002-315652 supports claims 54-74, and JP 2002-315654 supports claims 75-82. These verified English translations perfect Applicants’ priority claims, whereby a priority date for the instantly claimed invention has been established as October 30, 2002. Gyoutoku et al. has a filing date of September 22, 2003, i.e. subsequent to the established priority date, and accordingly, Gyoutoku et al. is not available as prior art, whereby the rejection based on this reference cannot be maintained.

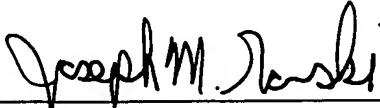
Accordingly, it is respectfully submitted that the application is now in condition for allowance,

In view of the above amendments and remarks, it is respectfully submitted that the present application is in condition for allowance, with the allowed claims being 44-82, and an early Notice of Allowance is earnestly solicited.

If after reviewing this Amendment, the Examiner believes that any issues remain which must be resolved before the application can be passed to issue, the Examiner is invited to contact the Applicants' undersigned representative by telephone to resolve such issues.

Respectfully submitted,

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DESCRIPTION

LIGHT SOURCE FOR IMAGE WRITING APPARATUS AND
PRODUCTION METHOD FOR LIGHT SOURCE

5

Technical Field

The present invention relates to a light source for an image writing apparatus and a production method of the light source.

10

Background Art

Some color laser printers (~~which is called~~ a printer hereinafter) 100 employ ~~the a~~ printing method called ~~the a~~ tandem method that enables the printer to print in parallel a visible image consisting of four colors, Y (yellow), M (magenta), C (cyan) and B (black), as shown in Fig. 1, so that the printer can perform ~~the high-speed~~ printing. In order to form ~~the a~~ four-colored visible image in parallel, the printer 100 employing the tandem method is provided with 4 four sets of writing systems 110, with each system including an electric discharger 105, a photosensitive drum 106, an electric charger 107, a light source 200, and a developing device 108, as shown in Fig. 2.

20

A recording paper 120 on a tray 101 as shown in Fig. 1 is fed ~~to in~~ a traveling route 103 inside the printer 100 by a carrying roller 102. While the carrying roller ~~120-102~~ is carrying the recording paper 120, ~~the writing~~ light emitted from the light source 200 forms a latent image on each photosensitive drum 106 per color, and then the developing device 108 forms a visible image.

25

The visible image formed on each photosensitive drum 106 is transcribed on the recording paper 120 ~~on-in~~ the traveling route 103, and then a fixing device 109 fixes the visible image thereon. After that, the recording paper 120 is outputted from the printer 100.

5 The light source 200 is provided with a substrate 601 extended ~~to-in~~ the a main scanning direction on which light emitting elements 8 consisting of a number of LEDs (Light emitting Diode) are formed, as shown in Fig. 3. ~~The~~ Each light emitting element 8 emits a ray of light A in ~~the~~ a direction perpendicular to the substrate 601. As shown in Fig. 3, the ray A passes
10 through ~~the~~ light transmitting ~~means~~ structure 310 such as ~~the~~ a rod lens or ~~the~~ a fiber lens, which composes the light source 200, and forms the latent image on the photosensitive drum 106.

The light transmitting ~~means~~ structure 310 has a narrow angular aperture and ~~the~~ a depth of ~~the~~ focus is kept-maintained to be long so that ~~the~~ a
15 clear latent image may be formed on the photosensitive drum in a simple manner.

~~Disclosure~~ Summary of the Invention

In order to emit light A toward the photosensitive drum 106, the
20 substrate 601 is configured, as shown in a short side of substrate 601, ~~is-as~~ parallel with ~~the~~ a sub-sub-scanning direction (~~the~~ a direction perpendicular to ~~the~~ an axis of the photosensitive drum 106), and a surface of the substrate 601 on which ~~the~~ light emitting elements 8 are formed faces the photosensitive drum 106.

25 It is said that ~~the~~ each light emitting element 8 must be ~~in-of~~ a specific

size in order that the light source 200 outputs ~~the~~ luminous intensity ~~enough-~~
~~sufficient~~ to form a latent image. And, the substrate 601 must be provided
 with accessories such as a driver to emit light from the light emitting element 8.
 Therefore, the short side of the substrate 601 should be a predetermined length.

5 Under the above-mentioned configuration, that is, when the short side of
 the substrate 601 is parallel with the ~~sub-sub~~-scanning direction and the surface
 provided with the light emitting elements 8 faces the photosensitive drum 106,
 if the short side of the substrate is long, the ~~sub-sub~~-scanning direction of the
 writing system 110 per color becomes long.

10 In ~~the-a~~ tandem type of the printer 100, 4 ~~four~~ colors writing systems 110
 are disposed in series in the ~~sub-sub~~-scanning direction. Even if ~~the-a~~ length of
 the writing system 110 becomes a little longer in the ~~sub-sub~~-scanning direction,
 slightly, the printer 100 becomes ~~big~~ large.

15 Recently, ~~the-a~~ laser printer has been required to print an image with
 high resolution. In order to print ~~the-an~~ image with high resolution, the
 printer must increase ~~the~~-resolution in the ~~sub-sub~~-scanning direction. This
 increases ~~the-a~~ number of ~~the~~-scanning per length unit in the ~~sub-sub~~-scanning
 direction, with ~~the-a~~ result that ~~the-a~~ printing time ~~gets-long~~ increases. To
 print ~~the-an~~ image with high resolution in a short time, ~~the-exposure~~ time per
 20 ~~sub-sub~~-scanning line should be shortened. But in such case, it is not possible
 to obtain ~~the-sufficient~~ exposure ~~enough~~ to form ~~the-a~~ latent image on the
 photosensitive drum 106.

25 Additionally, in order to print ~~the-an~~ image with high resolution by an
 electro photographic type of printer 100, a number of ~~the~~-light emitting
 elements must be disposed in ~~the-a~~ ~~sub-sub~~-scanning direction with narrowing

of each space. In order to dispose a number of the light emitting elements with
while narrowing each space, ~~the~~ a size of the light emitting element 8 must be
small. If the size of the light emitting element 8 was small, ~~the~~ brightness of
each light emitting element ~~went down~~ decreased. ~~—And this~~ which reduces the
5 luminous intensity on the photosensitive drum 106.

A method, which increases ~~the~~ exposure on the photosensitive drum 106
without slowing down ~~the~~ printing speed, and instead of changing the size of the
light emitting element 8, is to improve ~~the~~ light transmission efficiency by
enlarging an angle aperture of a lens composing the light transmitting means-
10 structure 310. However, when the angle aperture was enlarged, ~~the~~ a focal
depth was ~~made short~~ shortened. Accordingly, it is hard to form a clear latent
image on the photosensitive drum 106. And, another method is to increase ~~the~~
brightness of the light emitting element 8 by applying much electric field
thereon. But, applying ~~the~~ much electric field on the light emitting element 8
15 not only reduces ~~the~~ luminescence life of the light emitting element 8 but also
increases ~~the~~ power consumption.

The present invention has an object to provide a light source for an
image writing apparatus, wherein the light source ~~that~~ forms a latent image
with high resolution without preventing ~~the~~ downsizing of ~~the~~ a printer and has
20 a long luminescence life, and another object to provide a production method
thereof.

The present invention suggests a light source for image writing
apparatus that can radiate light ~~to~~ in a normal direction to a photosensitive
drum, regardless ~~independent of the~~ a direction of a substrate provided with ~~the~~
25 light emitting elements, by converting an advancing direction of ~~the~~ light

emitted from a light emitting element.

The light source of image writing apparatus of the invention is provided with ~~a~~ converting ~~means~~ structure for converting the advancing direction of light. The converting ~~means~~ structure may be a prism or a light guide for
 5 converting the advancing direction of light by reflecting the light therein once or plural times.

In a conventional configuration, which is not provided with the converting ~~means~~ structure, ~~the~~ a short side of the substrate should be parallel with ~~the~~ a sub-scanning direction, and ~~the~~ a light emitting
 10 surface should face the photosensitive drum, in order that ~~the~~ light irradiates the photosensitive drum. But the light source of the invention, which is provided with the converting ~~means~~ structure, can eliminate ~~the~~ necessity of such configuration. In other words, the light source of the invention is configured that, when ~~the~~ a height of the substrate (~~the~~ a
 15 length from the light emitting surface to ~~the~~ an upper end of ~~the~~ a sealing glass) is less than the short side of the substrate, ~~the~~ a height direction of the substrate is parallel with the ~~sub-scanning~~ sub-scanning direction, and a surface formed by ~~the~~ a longitudinal direction and height direction of the substrate faces the photosensitive drum. According to such
 20 configuration, it is possible to ~~carry out~~ provide ~~the~~ a light source having a short sub-scanning direction, and downsize the light source.

Additionally, in the invention, the light source of the image writing means is provided with ~~the~~ directivity ~~means~~ structure for imparting ~~the~~ directivity to ~~the~~ light emitted from ~~the~~ a light emitting element and
 25 guiding the light to ~~the~~ light transmitting ~~means~~ structure. According to

~~the~~ this configuration, it is possible to improve ~~the~~ efficiency of ~~the~~ light transmission ~~keeping while maintaining the~~ an angle aperture small.

The light transmitting ~~means~~ structure may be a fiber lens that is formed by a plurality of single lenses. ~~Besides~~ Additionally, one of single lenses
 5 may correspond to one of light emitting elements so as to pass ~~the~~ light emitted from the light emitting element through ~~the~~ this single lens.

According to the above-mentioned configuration, ~~the~~ light from the light emitting element is guided to the light transmitting ~~means~~ structure efficiently, and it is possible to eliminate ~~the~~ necessity of using ~~the~~ a light
 10 transmitting ~~means~~ structure having a large angle aperture.

~~A~~ Condensing ~~means~~ structure is provided between the light emitting element and the photosensitive drum, whereby ~~the~~ light is transmitted to the photosensitive drum through the condensing ~~means~~ structure. When the light, even if the light has a large light emitting area, irradiates the photosensitive
 15 drum, a sectional area becomes small. Therefore, ~~the~~ a light emitting element with ~~the~~ a large light emitting area can form a latent image with small pixels on the photosensitive drum.

When ~~the~~ an electronic photographic type of printer prints ~~the~~ an image with high resolution, a number of light emitting elements must be disposed
 20 within a specific section in the main scanning direction. Accordingly, the light emitting element has a limitation in ~~the~~ a length of the main scanning direction. But, ~~the~~ a length of the ~~sub-sub~~ scanning direction is not limited in particular. In ~~the~~ a case of condensing ~~the~~ light emitted from the light emitting element extended ~~to~~ in the ~~sub-sub~~ scanning direction by the condensing ~~means~~ structure,
 25 ~~the~~ a high luminous flux density can be increased. Therefore, after the

condensing ~~means-structure~~ condenses ~~the~~ light emitted from the light emitting elements extended ~~to-in~~ the ~~sub-sub~~ scanning direction, the light irradiates the photosensitive drum, so that ~~the~~ sufficient exposure to form ~~the-a~~ latent image can be obtained.

5 Therefore, it is not necessary to enlarge ~~the-an~~ angle aperture of the light transmitting ~~means-structure~~ in order to obtain ~~the-sufficient~~ exposure enough to form ~~the-a~~ latent image as above. And, ~~with-keeping-the~~ while maintaining a deep focal depth, ~~the-sufficient~~ exposure to form ~~the-a~~ latent image can be obtained.

10 When a flat luminous type of light emitting element is formed directly on the light transmitting ~~means-structure~~, ~~the~~ light emitted from the light emitting element is transmitted directly to the light transmitting ~~means-structure~~ without passing through a low refractive index layer with ~~the-low~~ directivity. And most of ~~the-rays~~ of light reach the photosensitive drum without a leakage, with ~~the-a~~ result that the light can reach the photosensitive drum ~~keeping-~~ the while maintaining sufficient luminous intensity. Accordingly, since it is not necessary to apply ~~the-a~~ high electric field on the light emitting element to increase ~~the-brightness~~, it is possible to form ~~the-a~~ latent image with high resolution without reducing ~~the-luminescence~~ life. And, since the angle

15 aperture of the light transmitting ~~means-structure~~ is not required to be large to form the latent image, ~~the-a~~ focal depth can be maintained ~~in-deep~~.

20

 In addition, ~~it-the~~ light source may be configured such that one of the light emitting elements corresponds to a plurality of ~~the-single~~ lenses. Under such configuration, a width of ~~the-each~~ single lens is smaller than a diameter of

25 ~~the-a~~ corresponding light emitting element, so that the light emitting element

can be formed with disregard to ~~the~~ a positional relationship between the light emitting element and the single lens. This makes ~~the producing~~ production easy.

Moreover, the light source of image writing apparatus may be configured
 5 to be provided with ~~a-directivity means-structure~~ between the light emitting element and the light transmitting ~~means~~structure, and to form the light transmitting structure~~means~~, the directivity structure~~means~~, and the light emitting element in a unit optically. The directivity structure~~means~~, optically formed with the light transmitting structure ~~means~~-and the light emitting
 10 element, has a mesa structure, and the light emitting element is disposed on an upper surface of the mesa structure. According to such configuration, ~~the~~ transmission efficiency can be improved.

~~Besides~~Additionally, the directivity ~~means-structure~~ may be a light guide for imparting ~~the-directivity to the~~ a ray of light by reflecting ~~the-light~~
 15 therein once or plural times.

The light source, of which ~~the~~ a flat luminous type of the light emitting element is formed directly on the light transmitting ~~means~~structure, can be produced according to the following ~~way~~manner. A transparent electrode element is formed on the light transmitting ~~means-structure~~ directly, and a light
 20 emitting layer element including a flat luminous unit is formed on the transparent electrode element, and then a metal electrode layer is formed on the light emitting element.

Otherwise, when the directivity structure ~~means~~-is formed with the light transmitting structure ~~means~~-and the light emitting element ~~in-as~~ a single piece,
 25 the directivity structure ~~means~~-is formed on the light transmitting structure

~~means directly, and the transparent electrode element is formed on the~~
~~directivity structure means, and the transparent electrode element is formed on~~
~~the directivity structure means, and the light emitting element consisting of the~~
 flat luminous unit is formed on the transparent electrode element, and then the
 5 metal electrode element is formed on the light emitting element.

Brief Description of the Drawings

Fig. 1 is an outline view of ~~the a~~ printer.

Fig. 2 is an enlarged view of ~~the a~~ light source part.

10 Fig. 3 is an outline view of ~~the a~~ light source.

Fig. 4 is a sectional view of ~~the a~~ light source using ~~the a~~ prism as ~~the~~
 converting ~~means~~ structure, and ~~the a~~ photosensitive drum.

Fig. 5 shows steps (A) to (D) for producing ~~the a~~ light emitting element.

Fig. 6A is an external view of ~~the~~ light transmitting ~~means~~ structure, Fig. 6B
 15 is an enlarged view of Fig. 6A, and Fig. 6C is an enlarged view of Fig. 6B-.

Fig. 7A is an outline view of ~~the a~~ light source and ~~the a~~ photosensitive
 drum of ~~the an~~ image writing apparatus, and Fig. 7B is another outline view of ~~the a~~
 light source and ~~the a~~ photosensitive drum of ~~the other~~ another image writing
 apparatus.

20 Figs. 8A to 8C are diagrams showing light guides having different shapes,
 respectively.

Fig. 9 is a sectional view of ~~the a~~ light source using a light guide as ~~the~~
 converting ~~means~~ structure, and ~~the a~~ photosensitive drum.

Fig. 10 is a sectional view of ~~the a~~ light source using a light guide as ~~the~~
 25 converting ~~means~~ structure.

Fig. 11 is a sectional view of ~~the~~a light source using a prism as ~~the~~
converting ~~means~~structure.

Fig. 12 is a sectional view of ~~the~~a light source using a prism as ~~the~~
converting ~~means~~structure.

5 Fig. 13 is a sectional view of ~~the~~a light source using a light guide as ~~the~~
converting ~~means~~structure, and ~~the~~a photosensitive drum.

Fig. 14 is a sectional view of ~~the~~a light source using a prism as ~~the~~
converting ~~means~~structure.

10 Fig. 15 is a sectional view of ~~the~~a light source using a light guide as
converting ~~means~~structure.

Fig. 16 is an outline view of ~~the~~a light source and ~~the~~a photosensitive
drum of ~~the~~an image writing apparatus ~~in~~of the invention.

Fig. 17 is an outline view of ~~the~~a transparent substrate on which small
projections are formed.

15 Fig. 18 is a diagram showing a track of ~~the~~a ray of light emitted from
~~the~~a light emitting element.

Fig. 19 shows steps (A) to (D) for producing ~~the~~a light emitting element.

Fig. 20 shows steps (A) to (B) for producing a small projection by ~~means~~of
~~the~~performing anisotropic etching.

20 Fig. 21 is a general view of a bead sheet and ~~the~~light transmitting
~~means~~structure.

Fig. 22 shows steps (A) to (C) for producing ~~the~~a light emitting element on
the bead sheet.

25 Fig. 23 is a diagram showing a track of ~~the~~a ray of light emitted from
~~the~~a light emitting element.

Fig. 24 shows ~~the a~~ light source of ~~the an~~ image writing apparatus using a micro lens alley as ~~the-directivity means~~structure.

Fig. 25 is an outline view of ~~the a~~ light source and ~~the a~~ photosensitive drum of ~~the an~~ image writing means using a micro lens alley as ~~the-directivity means~~structure.

Fig. 26 is a diagram showing a track of ~~the a~~ ray of light emitted from ~~the a~~ light emitting element.

Fig. 27 is a diagram showing a track of ~~the a~~ ray of light emitted from ~~the a~~ light emitting element.

Fig. 28 shows steps (A) to (B) for producing ~~the a~~ light guide by ~~means- of performing~~ the etching.

Fig. 29 is an outline view of ~~the a~~ light source and ~~the a~~ photosensitive drum using a cylindrical lens as ~~the-condensing means~~structure.

Fig. 30 is an outline view of ~~the a~~ light source and ~~the a~~ photosensitive drum using a micro lens as ~~the-condensing means~~structure.

Fig. 31 is an enlarged diagram of a ~~periphery-peripheral portion of the a~~ ray of light emitting element when ~~the a~~ ray of light emitted from the light emitting element is emitted to ~~the a~~ metal electrode layer side.

Figs. 32A and 32B show examples of the light source when the ray of light emitted from the light emitting element is emitted to the metal electrode layer side.

Fig. 33 is an outline view of ~~the a~~ light source in ~~embodiment-~~ Embodiment 11 of the invention.

Fig. 34 is an outlined block diagram of ~~the a~~ light emitting element.

Fig. 35 is an outline view of ~~the a~~ light source in ~~embodiment-~~ Embodiment 12 of the invention.

Fig. 36A is a diagram illustrating ~~the~~a non mesa-structure, and Fig. 36B is a diagram illustrating ~~the~~a mesa-structure.

Fig. 37 shows steps (A) to (eC) for producing ~~the~~a light source in ~~embodiment~~Embodiment 13.

5

~~Best Mode for Carry Out the Invention~~Detailed Description of the Preferred Embodiments

Embodiment 1

10

A light source 200 for image writing apparatus in the invention is applied as a light source to ~~the~~a color laser printer (which is called a printer hereinafter) 100 shown in Fig. 1, like ~~the~~a conventional way.

15

The light source 200 in this embodiment is composed of a transparent substrate 301 and ~~a~~light transmitting means-structure 310 that are extended ~~to~~
in ~~the~~a main scanning direction as shown in Fig. 4. On one surface of the transparent substrate 301, a row composed of a plurality of light emitting elements 8 is formed in ~~the~~a long side direction of the transparent substrate 301 by ~~means~~performance of a following method.

20

First, a transparent electrode layer 2 like ITO (Indium Tin Oxide) is applied on ~~the whole~~an entire surface of the transparent substrate 301, as shown in Fig. 5(A).~~—), and~~And a shading film 3 masks a section of the transparent electrode layer 2, with this the-section being one on which a transparent electrode element 1 is to be formed as an anode. The ~~formed~~
transparent electrode layer 2 is subjected to ~~the~~photolithography, such as ~~the~~
25 exposure, ~~the~~development, and ~~the~~etching. After the photolithography, ~~the~~

other sections without ~~the~~ masking are removed from the transparent substrate 301, as shown in Fig. 5(B), ~~and~~ and each masked section becomes the transparent electrode element 1. A plurality of sections on the transparent substrate 301 are masked at fixed intervals in ~~the~~ a longitudinal direction, and thereby a row of ~~the~~ transparent electrode elements 1 is formed in the longitudinal direction.

In ~~the~~ a next step, an organic EL (Electro Luminescence) material is applied ~~on over~~ on the ~~the whole~~ surface of the transparent substrate 301, including the surface on which the transparent electrode elements 1 are formed, as shown in Fig. 5(C), which forms an organic EL layer 4. On ~~the~~ a surface of the organic EL layer 4, ~~the~~ metal to be a metal electrode layer 5 is applied as ~~the~~ a common electrode. The organic EL layer 4, which is sandwiched between the metal electrode layer 5 and the transparent electrode element 1, becomes a light emitting element 8.

~~Besides~~ Additionally, in order to protect the organic EL layer 4 from a physical impact or ~~the~~ moisture, the organic EL layer 4 is subjected to ~~the~~ sealing. As shown in Fig. 5(D), the sealing is ~~the~~ processing that in which an adhesive resin 6, like epoxy resins including ~~the~~ a glass filler, is applied on a sealing section 304 and the metal electrode layer 5 and the resin 6 are sealed by ~~the~~ sealing glass 7. The light emitting element 8 thus formed emits a ray of light A in ~~the~~ a direction perpendicular to the transparent substrate 301, and ~~the~~ ray A passes through the transparent electrode element 1 and is discharged from the transparent substrate 301, as shown in Fig. 5(D).

The transparent substrate 301 is disposed so that ~~the~~ surface G formed by ~~the~~ long side direction L and ~~the~~ height direction H of the transparent

substrate 301 faces a photosensitive drum 106, as shown in Fig. 4.

And a ~~a~~-an orthogonal prism 401 extended ~~to~~-in the main scanning direction is disposed on a surface (which is called a light emitting surface 301a hereinafter) opposite to the surface on which the light emitting elements are formed, and ~~the~~-this disposed position corresponds to the row of the light emitting elements. Accordingly, the ray A emitted from the light emitting element 8 passes through both the transparent electrode element 1 and the transparent substrate 301, and comes into the prism 401 from the light emitting surface 301a.

As shown in Fig. 4, one surface making a right angle of the orthogonal prism is disposed on the transparent substrate 301. The ray A incident from the surface ~~turns the~~changes direction by a slanting surface 401a and is discharged from another surface making the right angle of the orthogonal prism. Accordingly, ~~the~~-an advancing direction of the ray A converts ~~the~~-to a direction parallel to the transparent substrate 301 (~~the~~-a normal direction of the photosensitive drum 106).

The light transmitting ~~means~~-structure 310 is disposed between the prism 401 and the photosensitive drum 106, so as to form a latent image on the photo sensitive drum 106 by the ray A emitted from the prism 401. In this embodiment, the light transmitting ~~means~~-structure 310 is supported by the transparent substrate 301.

The light transmitting ~~means~~-structure 310 is provided with a lens alley binding a plurality of optical lenses like a-fiber lenses 313, a-rod lenses, or a-micro lenses. ~~The~~-An optical lens used ~~to~~-for the lens alley may be an image transmitting type or a type of transmission for ~~the~~-light intensity.

As shown in Fig. 6A and 6B, ~~the~~ a fiber lens alley is disposed within a space surrounded by two base frames 311 and a light absorbing layer 312 so that each axis of ~~the~~ fiber lenses may face ~~to the~~ in a normal direction of the light sensitive drum 106. ~~The~~ Gaps in ~~the~~ a space in which ~~the~~ fiber lens alleys are disposed are filled with an opaque resins.

The light absorbing layer 312 prevents ~~the~~ crosstalk between the fiber lenses 313. To prevent the crosstalk, instead of providing the light absorbing layer between the two base frames 311, the opaque resins to be the light absorbing layer 312 may be applied on ~~the~~ a circumference-circumferential surface of each fiber lens 313. In addition, the crosstalk can be prevented by using both the light absorbing layer 312 provided between the base frames 311 and the light absorbing layer 312 applied on the ~~circumference-circumferential surface~~ of the fiber lens ~~312~~313.

The ray A of which the advancing direction is converted by the prism 401 passes through the light transmitting ~~means-structure~~ 310 and illuminates the photosensitive drum 106, with ~~the~~ a result that ~~the~~ a latent image is formed.

As described above, the light source 200 is provided with the prism 401 as a converting ~~means-structure~~ for changing the advancing direction of the ray A, and thereby the ray A emitted from the light emitting element 8 can illuminate the photosensitive drum 106 without facing the light emitting surface 301a of the transparent substrate 301, ~~to the photosensitive drum-like~~ the a conventional way.

Fig. 7A shows a sectional view of ~~the~~ a writing system 110, wherein a height h between the light emitting surface 301a and ~~the~~ a top of ~~the~~ sealing glass 7a is shorter than a shorter side s of the transparent substrate 301, and

the shorter side s of the transparent substrate 301 is disposed so as to be parallel with ~~the a~~ sub-scanning direction while the light emitting surface 301a of the transparent substrate 301 is disposed so as to face to the photosensitive drum 106 in the ~~same as~~ conventional way. And, Fig. 7(B) shows a sectional view of ~~the~~ writing system 110, wherein ~~the~~ surface G formed by both ~~the~~ long side direction L and ~~the~~ height direction H of ~~the~~ transparent substrate 301 is disposed so as to face ~~to~~ the photosensitive drum 106 ~~like as in~~ Fig. 4. As shown in Fig. 7 (B), the ~~sub-sub~~ scanning direction of the light source 200 ~~gets becomes~~ shorter by disposing the surface G so as to face the photosensitive drum 106. Accordingly, it is possible to ~~carry out~~ provide the writing system 110 with ~~the a~~ shorter ~~sub-sub~~ scanning direction.

If the ~~sub-sub~~ scanning direction of the light source 200 gets shorter, the writing system 110 shown in Fig. 2 has ~~the a~~ short ~~sub-sub~~ scanning direction, ~~whereby~~. ~~Thereby the a~~ pitch of each photosensitive drum becomes narrow, so that ~~the a~~ size of the printer 100 can be ~~downsized~~ reduced.

In addition, the prism 401 as the converting ~~means~~ structure in the above description converts the advancing direction of the ray A ~~in 90 degrees~~ as shown in Fig. 4, but ~~the degree an angle~~ to ~~convert which~~ the advancing direction is converted is changeable freely by adjusting ~~the degree an angle~~ of the slanting surface 401a.

Therefore, ~~the a~~ layout of the assemblies inside the printer 100 can be designed according to ~~the~~ downsizing of the printer and ~~the~~ facilities of ~~the~~ printer production rather than the advancing direction of the ray A.

~~Besides~~ Additionally, the above embodiment is explained based on that the prism 401 is used ~~to as~~ the converting ~~means~~ structure; however, ~~But the~~

converting ~~means-structure~~ may be a unit to convert the advancing direction of the ray A emitted from the light emitting element 8, and ~~the~~ a shape or material of the converting ~~means-structure~~ is not limited in particular.

5 Embodiment 2

The converting ~~means-structure, except for~~ instead of the prism 401, may be a light guide 402 as shown in Fig. 8, and the light guide 402 is made of a transparent material with a higher refractive index than ~~the~~ air and the transparent substrate 301. As shown in Fig. 8A, a reflection material 404 made of a material without ~~the~~ transparency, such as a metal, is layered over ~~an~~ a surface 407 opposite to an emitting surface 408 from which ~~the~~ ray A incident to the light guide 402 is emitted. Each light guide 402 is disposed on ~~the~~ light emitting surface 301a so as to contact an upper surface 405 ~~with~~ at an opposite position relative to ~~the~~ transparent electrode element 1, as shown in Fig. 9.

As described in Embodiment 1, the light emitting element 8 emits the ray A downward (~~the~~ light guide 402 side) in Fig. 9. Accordingly, the ray of light emitted from the light emitting element 8 passes through the transparent electrode element 1 and the transparent substrate 301, and comes into the light guide 402 through the upper surface 405 of the light guide 402.

~~Besides~~ Additionally, in order to reduce ~~the~~ occurrence of ~~the~~ crosstalk as much as possible when the ray A passes through the transparent substrate 301, the transparent substrate 301 should be thin.

As described above, the reflection material 404 is layered over the surface 407, and the refractive index of the light guide 402 is higher than that of ~~the~~ air and the transparent substrate 301. Therefore, the ray A incident into

the light guide 402 through the upper surface 405 repeats ~~the~~ total reflection in the light guide 402, and then is emitted from the emitting surface 408.

~~In~~ As a result, ~~the~~ an advancing direction of the ray A converts from ~~the~~ a downward direction to ~~the~~ a left side direction by passing through the light guide 402, that is to say, the direction is converted ~~with~~ by 90 degrees.

~~Besides~~ Additionally, the ray A emitted from the emitting surface 408 of the light guide 402 passes through the light transmitting ~~means~~ structure 310 and illuminates the photosensitive drum 106, whereby ~~the~~ a latent image is formed, like ~~embodiment~~ Embodiment 1.

In addition, the above explanation refers to ~~the~~ a case that the advancing direction of the ray of light is converted ~~with~~ by 90 degrees by using the light guide 402 as shown in Fig. 9. However, the advancing direction of the ray A is changeable freely by adjusting ~~the~~ a longitudinal direction of the light guide 402 relative to any direction of the ray A to be emitted, as shown in Fig.

10.

Moreover, in such a case that the above-mentioned light guide is used as the converting ~~means~~ structure, ~~the~~ a sectional area of light emitted from the light emitting surface 408 has the same size as the light emitting surface 408 regardless of ~~the~~ a size of a luminous area of the light emitting element 8.

Accordingly, forming the light emitting element 8 with a large light emitting surface on the transparent substrate 301 can increase ~~the~~ luminous flux density of ~~the~~ light emitted from the emitting surface 408.

Therefore, the light source 200 has a short ~~sub~~ sub scanning direction and outputs ~~the~~ light with higher luminous flux density by ~~means~~ using of the light guide 402 as the converting ~~means~~ structure. ~~Besides~~ Additionally, ~~the~~ a

shape of the light guide 402 ~~is~~ does not need to be a rectangular parallelepiped shown in Fig. 8A, but may be a pentagonal prism or a hexagonal prism shown in Fig. 8B or Fig. 8C.

5 Embodiment 3

Embodiments 1 and 2 ~~explains about the~~ a configuration ~~that of the~~ prism 401 or the light guide 402 ~~is~~ disposed on the light emitting surface 301a of the transparent substrate 301. Additionally, the prism 401 or the light guide 402 may be disposed on the same surface that the light emitting ~~surface~~ element 8 is formed, as shown in Fig 11 to Fig. 13.

That is to say, ~~the~~ prism 401 is disposed on ~~the~~ sealing glass 7 so as to emit ~~the~~ ray A emitted from the light emitting element 8 in ~~the~~ an opposite direction to that described in Embodiments 1 and 2, and to lead the ray A into the prism 401 though the sealing glass 7.

15 However, when the light source 200 is formed as described in Embodiment 1, an opaque metal electrode layer 5 is formed on ~~the~~ an upper side of the light emitting element 8 and the ray A cannot be emitted to the sealing glass 7. ~~The~~ A cathode must use ~~the~~ a material with a lower work function than the transparent electrode element 1 to be ~~the~~ an anode in order to improve ~~the~~ luminous efficiency of ~~the~~ organic EL, whereby the opaque metal electrode layer 5 is applied to the cathode.

25 ~~The~~ A thickness of the metal electrode layer 5 should be a specific value (approximate 100Å) permeable to ~~the~~ light so as to emit the ray A from ~~the~~ a side of the sealing glass 7. And, in order that ~~the~~ electric current flows uniformly over ~~the~~ thin metal electrode layer 5, an electrode layer 5a made of a

transparent material should be formed on the metal electrode layer 5.

According to such configuration, the ray A can be emitted to ~~the~~ in an upward direction in Fig. 11, and simultaneously, also be emitted to ~~the~~ in a downward direction. To prevent ~~the~~ downward emission, a reflection plate 309
5 should be provided between the transparent substrate 301 and the transparent electrode element 1.

Additionally, like Embodiment 1, ~~the~~ organic EL layer 4, the metal electrode layer 5 and the electrode layer 5a should be covered by ~~the~~ resin 6 and the sealing glass 7 in order to protect the organic EL layer 4 from ~~the~~ physical
10 impact and ~~the~~ moisture.

By reducing the thickness of the metal electrode layer 5, the ray A emitted from the light emitting element 8 is emitted from the sealing glass 7, and incident into the prism 401 provided on the sealing glass 7.

After the ray A incident into the prism 401 changes ~~the~~ an advancing
15 direction by being reflected on ~~the~~ slanting surface 401a, the ray A is emitted from the prism 401, like Embodiment 1.

As described above, when the prism 401 and the light emitting element 8 are provided on the same surface of the transparent substrate, the light transmitting ~~means-structure~~ is also provided on the same surface on which the
20 light emitting element 8 is formed. The prism 401 and the light transmitting ~~means-structure~~ 310 are disposed on the same surface on which the light emitting element 8 is formed in such way, and the transparent substrate 301 is not provided with anything on ~~the~~ a surface opposite to the surface on which the light emitting surface element 8 is formed. This makes it easy to handle ~~the~~
25 light source 200.

~~Besides~~Additionally, instead of disposing the prism 401 on the sealing glass 7 as above, the prism 401 or the light guide 402 may be disposed on the electrode layer 5a and the resin 6 as shown in Fig. 12 and Fig. 13. In such case, the prism 401 or the light guide 402 ~~involves~~performs ~~the-a~~ function as ~~of the~~ sealing glass ~~7~~.

Embodiment 4

~~The p~~Prism 401 or ~~the~~ light guide 402 may be disposed between ~~the~~ transparent substrate 301 and ~~the~~ light emitting element 8, as shown in Fig. 14 and Fig. 15.

When the prism 401 is disposed on the transparent substrate 301 as shown in Fig. 14, a support stand 502 in the shape of a ~~triangle~~triangular prism, which is made of ~~the~~ material with ~~the-a~~ lower refractive index than the prism 401, or of ~~the~~ opaque material, should be disposed on the transparent substrate 301 to support the prism 401. And the prism 401 is placed on the support stand 502 so that ~~the~~ slanting surface 401a of the prism may be contacted with ~~the-a~~ slanting side of the support stand 502.

By ~~means of the same way~~manner as in Embodiment 1 to form the light emitting element 8 on the transparent substrate 301, the light emitting element 8 is formed on the prism 401. And, ~~the~~ light transmitting ~~means~~structure 310 is disposed on the same surface of the transparent substrate 301 that the prism 401 is disposed.

As shown in Fig. 14, after ~~the~~ ray A emitted from the light emitting element 8 comes into the prism 401 through ~~the~~ transparent electrode element 1, the ray A changes ~~the-an~~ advancing direction by being reflecting-reflected ~~the~~

~~ray A on~~from the slanting surface 401a. ~~The~~This reflected ray A forms ~~the a~~ latent image on the photosensitive drum 106 through the light transmitting ~~means-structure~~ 310.

And, as shown in Fig. 15, the light guide 402 instead of the prism 401
 5 may be disposed between the transparent substrate 301 and the light emitting element 8 so that a lower surface 403 of the light guide 402 may face ~~to~~ the transparent substrate 301. In such case, ~~the~~ reflection material 404 must be layered over ~~the a~~ lower surface 403 of the light guide so as not to emit light from the lower surface 403.

10 The light guide 402 is provided with ~~the~~ light emitting element 8 thereon in the same way of forming the prism 401 thereon. ~~The r~~Ray A emitted from the light emitting element 8 is emitted from ~~the~~ emitting surface 408 after repeating ~~the~~ total reflection within the light guide 402 like Embodiment 2. This emitted ray A forms ~~the a~~ latent image on the photosensitive drum 106
 15 through the light transmitting ~~means-structure~~ 310.

As shown in Fig. 15, the ray A emitted from the light emitting element 8 is incident into the light guide 402 without passing through the transparent substrate 301. Therefore, there is a merit that ~~the~~ crosstalk in the transparent substrate 301 will not occur in ~~the a~~ writing system applying the configuration
 20 shown in Fig. 15, although ~~the~~ crosstalk in the transparent substrate 301 occurs ~~under~~ with the configuration shown in Fig. 9.

Embodiment 5

25 The A light source in this embodiment is provided with ~~the~~ transparent substrate 301 and ~~the~~ light transmitting ~~means-structure~~ 301-310 extended to

~~the~~in a main scanning direction as shown in Fig. 16. The transparent substrate 301 and the light transmitting ~~means-structure~~ 310 are supported respectively by a housing of ~~the~~ printer 100, or either of the transparent substrate 301 or the light transmitting ~~means-structure~~ 310 is supported by the housing, and both the transparent substrate 301 and the light transmitting ~~means-structure~~ 310 are fixed to the printer 100 by being connected by a spacer or the like not illustrated in the drawings.

The transparent substrate 301 is provided with a number of small projections 202d with ~~the-a~~ mesa structure of ~~the-a~~ frustum as shown in Fig. 17 in the main scanning direction at fixed intervals. The transparent substrate 301 and the small projections 202d are formed in one piece. For instance, when the light source 200 can print out an image with 2400 dpi, ~~the-a~~ distance between the small projections 202d is about $10\ \mu\text{m}$.

The ~~respective-small~~ projections 202d may be formed on ~~the-a~~ transparent substrate ~~301~~ to be the substrate 301 according to a following etching processing, or by embossing ~~the-a~~ resin, or may be formed with ~~the~~ transparent substrate 301 in one piece by ~~the~~ injection molding.

The A shape of ~~the-each~~ small projection 202d may not be ~~the-a~~ frustum, but may be a shape wherein angles G and H, with each angle formed by the transparent substrate 301 and a side surface 202c of the small projection 202d as shown in Fig. 18, make an acute angle, i that is, the shape may ~~apply-be~~ a frustum, a triangular frustum, a pentagonal frustum, or a polygonal frustum. ~~The-m~~ Material of the small projections 202d is to be permeable and preferably have the same refractive index as the light emitting element 8 of the light source 200. ~~Besides~~ Additionally, this embodiment is based on ~~the-an~~ organic

EL (Electro Luminescence) material with ~~the a~~ refractive index, about 1.7, as the light emitting element 8; therefore, the material of the projections 202d in this embodiment is preferable to ~~be the~~ have a refractive index of about 1.7.

The light emitting element 8 shown in Fig. 19(C) is formed on an upper surface 202a of each small projection 202d according to ~~the a~~ method as mentioned hereinafter.

On ~~a whole~~ an upper surface of ~~the transparent~~ substrate 301 on which the small projections 202d are disposed, ~~the transparent~~ electrode layer 2 is applied as shown in Fig. 19(A). Next, a position which is on a center of ~~the an~~ upper surface 202a of each small projection 202d, is masked by a shading film 3, ~~and~~ And the transparent electrode layer 2 is subjected to ~~the~~ photolithography like ~~the exposure, the development, and the etching.~~ After the photolithography, the transparent electrode layer 2 is removed from ~~the~~ parts on which the shading film was not laminated, as shown in Fig. 19(B), and ~~the masked parts becomes the transparent electrode elements 1.~~

Subsequently, ~~the organic~~ EL layer 4 is applied on the ~~whole~~ surface of the transparent substrate 301 ~~on which~~ including the transparent electrode elements 1 ~~are formed~~ as shown in Fig. 19(C), and on the organic EL layer 4 ~~the~~ metal electrode layer 5 is applied as ~~the a~~ common electrode. ~~The A~~ part of the organic EL layer 4 sandwiched between the metal electrode layer 5 and the transparent electrode element 1 becomes ~~the~~ light emitting element 8.

To protect the organic EL layer 4 from ~~the physical impact and the~~ moisture, ~~the resin~~ 6 is applied on ~~the sealing section~~ 304, and ~~the sealing glass~~ 7 is applied on ~~the a~~ rear surface of transparent substrate 301 on which the transparent electrode elements 1, the organic EL layer 4, and the metal

electrode layer 5 are formed, as shown in Fig. 19(D). ~~Besides~~ Additionally, a space 9 surrounded by the metal electrode layer 5, the resin 6, and the sealing glass 7 may be under vacuum or ~~be~~-filled with nitrogen.

Under the above-mentioned configuration, when a predetermined voltage is ~~impressed~~ applied between the transparent electrode element 1 and the metal electrode layer 5 of ~~the~~-light source 200, the light emitting element 8 emits ~~the~~-light. ~~The~~ Rays A, B and C thus emitted from the light emitting element 8 come from the upper surface 202a of the small projection 202d into the small projection 202d through the transparent electrode element 1 as shown in

Fig. 18.

Of the rays A, B and C which come into the small projection 202d, ~~the~~-ray A ~~of which~~ has an incident angle $\theta 1$ on the upper surface 202a which is small, ~~;~~ that is, ~~the~~ an advancing direction of the ray A is the same as or approximate to ~~the axis~~ an axial direction of ~~the~~-fiber lens 313. Accordingly, ~~the~~ this ray does not reflect within the small projection 202d but emits from ~~the~~ a bottom 202b of the small projection 202d into the transparent substrate 301.

On the other hand, ~~the~~-rays B and C, of which incident angles $\theta 1$ are large, are incident from the upper surface 202a, and reach ~~the~~ a side 202c of the small projection 202d.

Since the refractive index of the small projection 202d is 1.7, that is larger than the space 9 under vacuum or filled with ~~the~~-nitrogen, and the angles $\angle G$ and $\angle H$ are acute angles as shown in Fig. 18 as described above, an incident angle $\theta 2$ that the rays B and C with ~~the~~-large incident angle $\theta 1$ forms ~~on~~ with the side 202c of the small projection 202d becomes large. ~~In~~ As a result, it is likely that ~~the~~ a ray with a large incident angle $\theta 1$, like the rays B and C,

performs ~~the~~ total reflection on the side 202c. By the total reflection, the rays B and C are imparted with ~~the~~ directivity close to the ~~axis-~~axial direction of the fiber lens 303, and then emitted from the bottom 202b to the transparent substrate 301.

5 Therefore, after the ray of light with the large incident angle $\theta 1$ passes through the small projection 202d, ~~the-~~an advancing direction of the light is steered to the same direction as the ~~axis-~~axial direction of the fiber lens 313. That is to say, by transmitting ~~the~~ light through the small projection 202d, it is possible to increase ~~the-~~a volume of light by converging light within ~~the-~~a scope
10 of ~~the-~~an angle aperture of the fiber lens 303.

As ~~the~~ transparent substrate 301 shown in Fig. 16, another surface (front surface) opposite to the surface on which ~~the~~ small projections 202d are disposed, is disposed so as to face to the photosensitive drum 106 and
15 sandwiching ~~the~~ light transmitting ~~means-~~structure 310. Accordingly, ~~the~~ light thus emitted from ~~the~~ bottom 202b of the small projection 202d passes through the transparent substrate 301, and comes into the light transmitting ~~means-~~structure 310.

Since ~~the~~ advancing directions of most of light reaching the light transmitting ~~means-~~structure 310 are steered to the same as ~~the-~~an axis-axial
20 direction of each fiber lens 303 composing the light transmitting ~~means-~~structure 310, even if ~~the-~~an angle aperture of the fiber lens 303 is small, each ray of light is led into the light transmitting ~~means-~~structure 310, and illuminates the photosensitive drum 106 through the light transmitting ~~means-~~structure 310.

25 When the light emitting elements 8 are formed on the transparent

substrate 301 provided with the small projections 202d, ~~the~~a light transmission efficiency between the light emitting element 8 and the ~~photo-~~photo-sensitive drum 106 could be improved about a-four times as high as the a configuration without the projections.

5 Due to ~~the~~directivity means-structure like the small projection 202d, it is not necessary to make the angle aperture of the fiber lens 303 large in order to improve the light transmission efficiency. Accordingly, the light transmitting ~~means-structure~~310 can ~~keep~~maintain a long focal depth. This makes it possible to form a clear latent image on the photosensitive drum 106 with ease.

The above-mentioned etching is a dry etching for forming ~~the~~a mesa structure, for example.

15 When the small projection 202d is formed by ~~the~~ dry etching, a material to be a directivity imparting layer 801 is applied or evaporated on ~~the~~an whole entire surface of the transparent substrate 301 as shown in Fig. 20A. ~~The~~mMaterial of the directivity imparting layer 801 is the same as the small projection 202d. In ~~the~~a next step, ~~the~~ transparent electrode layer 2 is formed on ~~the~~an upper surface of the directivity imparting layer 801 by ~~the~~ coating or ~~the~~ evaporation. ~~The~~pPositions to form ~~the~~a transparent electrode element 1 20 on the transparent electrode layer 2 are covered by ~~the~~ shading film 3.

25 Regarding the transparent substrate 301 on which the transparent electrode layer 2 is formed as above, a reacting species is brought to a side forming section (sections 808) through a mask 809 for controlling ~~the~~a depth of ~~the~~ etching. The depth of the etching depends on ~~the~~a brought amount. Therefore, the mask 809 applies a metal mesh wherein each size of each

apertures is adjusted corresponding to the depth of the etching, for example. That is to say, some parts of the metal mesh corresponding to ~~the a~~ deep etching part (~~the a~~ center of the section 808) have ~~a large-large-sized~~ of apertures to increase ~~the a~~ brought amount of the reacting species, while ~~the other~~ parts corresponding to ~~the a~~ shallow etching part (~~the end~~ portions of the section 808) have ~~a small-small-sized~~ of apertures to reduce ~~the a~~ brought amount of the reacting species.

The etching removes ~~the~~ sections filled with the reacting species from the transparent electrode layer 2 and the directivity imparting layer 801, so that a number of projections 202d in a shape of polygonal frustum can be formed on the transparent substrate together with ~~the transparent~~ electrode element 1, as shown in Fig. 20B. The projections 202d become ~~the directivity~~ meansstructure.

As described above, both the directivity imparting layer 801 and the transparent electrode layer 2 are subjected to ~~the~~ etching simultaneously, with ~~the a~~ result that it is possible to reduce ~~the steps~~ of producing ~~the a~~ light source. And, where the transparent electrode element 1 is formed separately from the directivity imparting meansstructure, ~~the positioning for the masking is required.;~~ however, But such positioning becomes unnecessary by performing the etching simultaneously.

Embodiment 6

The above-mentioned directivity ~~means~~ structure may be configured by a beads sheet 220 of which projections are formed on a surface of ~~the transparent~~ substrate 301 extended to ~~the in a~~ main scanning direction by ~~the injection~~

molding, ~~with said the~~ surface facing to ~~the~~ light transmitting ~~means-structure~~ 310, as shown in Fig. 21. In ~~the-a~~ case of using the beads sheet 220 as the directivity ~~means-structure~~, ~~the~~ light emitting elements 8 are formed on another surface of the beads sheet 220 opposite to ~~the-a~~ surface on which the projections
 5 are formed, according to the following method.

First, ~~the-transparent~~ electrode layer 2 is applied on ~~the-whole-a~~ surface of the beads sheet 220, which is opposite to the surface with the projections, as shown in Fig. 22(A). And then, a position on the transparent electrode layer 2, where ~~the-transparent~~ electrode element 1 should be formed, is covered with ~~the~~
 10 shading film 3, like Embodiment 5.

And, ~~the~~ photolithography is performed, which forms the transparent electrode element 1 on ~~the-a~~ part masked by the ~~photolithography~~ shading film, as shown in Fig. 22(B). After that, ~~the-organic~~ EL layer 4 and ~~the-metal~~ electrode layer 5 are formed in the same way as in Embodiment 5. ~~In-As a~~
 15 result, the organic EL layer 4 sandwiched between the transparent electrode element 1 and the metal electrode layer 5 becomes ~~the-light~~ emitting element 8. ~~Besides~~ Additionally, like Embodiment 5, for ~~the-a~~ purpose of protecting the organic EL layer 4 from ~~the-physical~~ impact and ~~the-moisture~~, ~~the-resin~~ 6 is applied on ~~the-sealing~~ section 304, and the metal electrode layer 5 and the resin
 20 6 are covered by ~~the-sealing~~ glass 7.

Under such a configuration, ~~the-ray~~ A emitted from the light emitting element 8 is incident into the beads sheet 220 through the transparent electrode element 1 as shown in Fig. 23. The beads sheet 220 is provided with the projections on ~~the-a~~ surface facing to ~~the~~ light transmitting ~~means-structure~~ 310.
 25 There is a possibility that the ray A, at ~~the-a~~ time of ~~going-out-from~~ exiting the

beads sheet 220, has a smaller angle ~~against~~ relative to the projections than when the ray A is emitted from the a surface without projections. Therefore, the projections can reduce the leakage of the light emitted from the beads sheet 220, with the a result that it is possible to increase the a volume of light emitted from the beads sheet 220 to the light transmitting ~~means~~ structure 310.

When the light is emitted from the beads sheet 220, the light is imparted with the directivity because of the a difference of the a refractive index between the beads sheet 220 and the ~~outside~~ an exterior. That is to say, the light ~~turns~~ changes an advancing direction to the ~~axis~~ an axial direction of the fiber lens 303, and the light steers the advancing direction to the same direction as the axis direction of the fiber lens 303.

The beads sheet 220 used as the directivity ~~means~~ structure as described above can emit a large volume of light as well as can impart the directivity to the light. In As a result, when the light emitting elements 8 are formed on the beads sheet 220, the a light transmission efficiency between the light emitting element 8 and the photosensitive drum 106 could be improved about a twice as high much as the a configuration without the projections.

~~Besides~~ Additionally, the projections provided with the beads sheet 220 may be of a shape that is able to impart the light with the directivity as well as emit a larger volume of light from the beads sheet 220, such as a cone, a frustum of a cone, a dome, a triangular pyramid, a rectangular pyramid, and so on ~~the~~ like.

And, the a size of the projections of the beads sheet 220 is not limited in particular, but it is desirable to be smaller than the light emitting element 8.

For instance, if the size of the ~~each~~ projection is the same as the light emitting

element 8, ~~the assembling of the light source 200 requires a step of the~~
positioning to correspond the projection to the light emitting element 8 so that
the light from the light emitting element 8 might be discharged from one
projection. But, ~~as smaller the~~ for a projection is smaller in size, ~~the a~~ number
5 of the projections through which the light from each light emitting element
passes becomes approximate to ~~the a~~ number of the light emitting elements 8
without the positioning of the projection and the light emitting element 8.
Therefore, it is possible to diminish the dispersion of the transmission efficiency
of the light from each light emitting element 8 and the directivity to be
10 imparted.

In addition, since the beads sheet 220 is provided with functions of both
the directivity ~~means~~ structure and the transparent substrate 301 as described
above, it is possible to omit ~~the a~~ positioning step of the small projections 202d
as described in Embodiment 1 from ~~the an~~ assembling process of ~~the a~~ light
15 source provided with the beads sheet 220.

Embodiment 7

In Embodiment 7, instead of the beads sheet 220 with the projections
provided ~~to for~~ the transparent substrate 301 as the directivity ~~means~~ structure,
20 a micro lens alley 230 may be disposed between the transparent substrate 301
and the light transmitting ~~means~~ structure 310 as the directivity
means structure, as shown in Fig. 24.

~~The A producing production~~ process for forming the light emitting
element 8 on the transparent substrate 301 is the same as in Embodiment 6
25 except for a step that ~~the each~~ light emitting element 8 is formed on the

transparent substrate 301 without ~~the~~ projections.

The micro lens alley 230 to be used as the directivity ~~means-structure~~ is produced by ~~the~~ injection molding or by irradiating ~~the~~ ultraviolet rays on ~~the~~ to a photosensitive glass.

5 The micro lens alley 230 is supported by the transparent substrate 301 through ~~the~~ a spacer S as shown in Fig. 24, for example.

~~The~~ light from the light emitting element 8 ~~are~~ is incident to the micro lens alley 230 through the transparent substrate 301. ~~And~~ ~~and~~ when the light is emitted from the micro lens alley 230, ~~the~~ ~~an~~ advancing direction of the light
10 is converted in the same way as emitting the light from the beads sheet 220.

~~And~~ ~~Thus~~, most advancing directions of the light are converted to the same direction as ~~the~~ ~~axis~~ an axial direction of ~~the~~ fiber lens 303.

~~Besides~~ Additionally, ~~the~~ ~~a~~ size of the micro lens is not limited in particular. ~~But~~ but it is desirable to be smaller than ~~the~~ transparent electrode
15 element 1 like the size of ~~the~~ ~~a~~ projection of the beads sheet 220.

Embodiment 8

The above embodiment relates to ~~the~~ ~~a~~ configuration so as to improve ~~the~~ transmission efficiency of ~~the~~ light between the light emitting element 8 and the
20 photosensitive drum 106 by changing ~~the~~ ~~an~~ advancing direction of the light, and ~~the~~ illuminance on the photosensitive drum. The following explains ~~about~~ ~~the~~ ~~a~~ configuration so as to improve ~~the~~ illuminance on the photosensitive drum by improving ~~the~~ ~~a~~ luminous intensity of each light emitting element 8.

In order to improve the luminous intensity of each light emitting
25 element 8, ~~the~~ respective light emitting elements 8 in this embodiment have a

large luminous area. As described above, in order to print an image with high resolution, each light emitting element 8 must be disposed at a small interval in the main scanning direction. Accordingly, ~~the a~~ length of the light emitting element 8 in the main scanning direction is limited.

5 However, regarding the sub-scanning direction, the length is not limited at all. Accordingly, if the length of the light emitting element 8 is extended in the ~~sub-sub~~-scanning direction, ~~the a~~ size of the light emitting elements 8 can be enlarged. ~~The l~~Light emitted from the light emitting element 8 extended in the ~~sub-sub~~-scanning direction has a long section in the sub-scanning direction. In
10 As a result, the a latent image formed on the photosensitive drum 106 has pixels extended relative to the sub-scanning direction. In order to prevent the pixels from being extended relative to the sub-scanning direction, ~~the a~~ length of ~~the a~~ section of the light in the sub-scanning direction must be the same as ~~the~~
~~enethat~~ in the main scanning direction before the light emitted from the light
15 emitting element 8 reaches the photosensitive drum 106.

In this embodiment, ~~the~~ light guide 402 is used as a condensing ~~means-~~
structure for condensing ~~the~~ light from the light emitting ~~means-elements~~ 8 into
the sub-scanning direction.

As described in Embodiment 2, the reflection material 404 not
20 permeable to light is layered over the surface 407 opposite to the emitting
surface 408 of the light guide 402.

~~The l~~Light guides 402 are disposed on the transparent substrate 301 in
the main scanning direction at fixed intervals. The fixed intervals are the
same as ~~the~~ intervals of pixels of ~~the a~~ printing image. ~~Besides~~Additionally, in
25 order to avoid ~~the~~ crosstalk of ~~the~~ light incident to each light guide 402, ~~the a~~

space between the light guides 402 may be formed as an air layer or filled with the material having ~~the a~~ refractive index smaller than the light guide 402.

The light emitting elements 8 are formed on each light guide 402 in the same way as forming the light emitting element 8 on the small projection 202d in Embodiment 17. It is sure that ~~the~~ sealing section 304 is applied with ~~the~~ resin 6, and ~~the~~ metal electrode layer 6-5 and the resin 6 are covered with ~~the~~ sealing glass 7 in order to protect ~~the~~ organic EL layer 4 from ~~the~~ physical impact and ~~the~~ moisture, which is not shown in Fig. 25.

In a sectional view (Fig. 26) of Fig. 25, ~~the~~ ray A emitted from the light emitting element 8 is incident to the light guide 402 through the transparent electrode element 1. ~~It is configured t~~That the light guide 402 has ~~the a~~ refractive index larger than the transparent substrate 301, a vacuum status, or ~~the~~ air, and the reflection material 404 is layered over the surface 407 of the light guide 402. The ray A incident to the light guide 402 is reflected within the light guide 402 repeatedly, and then the ray exits from the emitting surface 408. As the ray A emitted from the light emitting element 8 is emitted from ~~the~~ emitting surface 408, ~~the a~~ section of the light emitted from the light emitting element 8 is the same size as the emitting surface 408.

Therefore, ~~the a~~ section of the emitting surface 408 may be formed so as to have the same area as ~~the an~~ area required ~~to the~~for pixels of ~~the a~~ latent image formed on the photosensitive drum 106. ~~In As a~~ result, even if ~~the a~~ luminous surface of the light emitting element 8 has any shape, the section of the light emitted from the emitting surface 408 is the same area as required.

Accordingly, the larger the luminous area of the light emitting element 8 becomes, the more the luminous flux density of the light emitted from the

emitting surface 408 can increase. Since ~~the~~a length of the ray emitting element 8 in the ~~sub-sub~~sub-scanning direction is not limited in particular as mentioned above, the light emitting element 8 may be formed on the light guide 402 so as to be long in the ~~sub-sub~~sub-scanning direction. This makes it possible to obtain ~~the~~a high luminous flux density on the emitting surface 408. In addition, since the light ~~are~~is condensed in the ~~sub-sub~~sub-scanning direction, it is possible to obtain on the emitting surface 408 the light with the high luminous flux density and with the same length both in the main scanning direction and the ~~sub-sub~~sub-scanning direction.

The ~~light~~Light source 200 provided with the light guide 402, wherein the light is emitted from the emitting surface 408, is provided with ~~the~~light transmitting ~~means-structure~~structure 310 in front of the light emitting surface 408 as shown in Fig. 25. The light emitted from the emitting surface 408 illuminates the photosensitive drum 106 through the light transmitting ~~means-structure~~structure 310 in the same way as described in Embodiments 5 through 7.

Therefore, the condensing ~~means-structure~~structure makes it possible to obtain ~~the~~the light with high luminous flux density even in the light source 200, wherein the light emitting elements 8 are formed in the main scanning direction at short intervals. Therefore, ~~the~~a light source with the condensing ~~means-structure~~structure can form ~~the~~a latent image with ~~the~~the high resolution.

Additionally, ~~the~~a luminescence life of the light emitting element 8 does not become short in using the light guide 402 as the condensing ~~means~~structure, because it is not necessary to apply a large electric field on the transparent electrode element 1 and the metal electrode layer 5 in order to obtain ~~the~~the light with ~~the~~the high luminous flux density as conventionally.

Moreover, ~~the~~a shape of the light guide 402 is not limited to a rectangular parallelepiped shown in Fig. 25. For instance, the shape may be a polygonal prism like a pentagonal prism ~~and or~~a hexagonal prism, or a shape with a polygonal bottom and an upper surface of a frustum of a cone as shown in

5 Fig.27.

~~Besides~~Additionally, although the light guide 402 may be produced by ~~the~~ injection molding, it may be produced by ~~the~~ etching as follows. For instance, a material 242 to be the light guide 402 is applied on the transparent substrate 301, and then ~~the~~ transparent electrode layer 2 is applied thereon, as shown in Fig. 28(A). Next, ~~the~~a position to form ~~the~~ transparent electrode element 1 on the transparent electrode layer 2 is masked by ~~the~~ shading layer 3, and then the transparent electrode layer 2 and the material 242 are subjected to ~~the~~ etching. Hereupon, the transparent electrode element 1 and the light guide 402 are produced as shown in Fig. 28(B).

15 As described above, since ~~the~~a sectional area of ~~the~~ light emitted from the light emitting element 8 can be made to be the same size as ~~the~~ pixels of the latent image by the light guide 402, if the light guide 402 is disposed so that the emitting surface 408 ~~be is~~ closer to the photosensitive drum 106, the light source 200 does not need to be provided with the transmitting ~~means~~structure 310.

20 And, if the emitting surface 408 is a convex surface such as ~~the~~a convex lens, ~~the~~ light ~~through~~from the emitting surface 408 is allowed to form an image on the photosensitive drum 106. It is ~~nevertheless~~needless to say that it is not necessary to provide the light source with the light transmitting ~~means~~structure if the emitting surface 408 is convex.

25

Embodiment 9

A convex cylindrical lens 250 may be ~~applied to the~~used as condensing ~~means~~structure, instead of the light guide 402. In such case, the cylindrical lens 250 may be disposed between the light transmitting ~~means~~structure 310 and the photosensitive drum 106 so as to ~~face~~direct ~~the~~a curved surface to the photosensitive drum 106 as shown in Fig. 29. The cylindrical lens 250 should be supported by the light transmitting ~~means~~structure 310 through a spacer not shown in ~~the this drawing figure~~, or by a housing of the printer 100.

~~The~~Light emitting element 8 may be formed on the transparent substrate 301 in the same way as Embodiment 6, but the light emitting element 8 in this embodiment is longer in ~~the~~a ~~sub-sub~~sub-scanning direction than in ~~the~~a main scanning direction, which is different from embodiment 6. ~~The~~A length of the light transmitting element 8 is long in the ~~sub-sub~~sub-scanning direction because the main scanning direction is limited as described in Embodiment 8. ~~Besides~~Additionally, Fig. 29 does not show, but it is also a matter of course in this embodiment that ~~the~~ metal electrode layer 5 may be covered by ~~the~~ resin 6 and ~~the~~ sealing glass 7 in order to protect ~~the~~ organic EL layer 4.

As shown in Fig. 29, ~~the~~ light emitted from the light emitting element 8 is incident into the cylindrical lens 250 through the transparent substrate 301 and the light transmitting ~~means~~structure 310. The light incident to the cylindrical lens 250 is narrowed down to the ~~sub-sub~~sub-scanning direction when the light exits from ~~the~~a convex surface of the cylindrical lens. And, ~~the~~a section of the light on the photosensitive drum has the same length both in the main scanning direction and the ~~sub-sub~~sub-scanning direction.

If the cylindrical lens 250 is used as the condensing ~~means~~structure, it is

possible to freely change ~~the a~~ length of the section of the light in the ~~sub-~~
~~sub-scanning~~ direction on the photosensitive drum 106 by adjusting ~~the a~~ radius
of curvature or ~~the a~~ refractive index of the cylindrical lens 250, or by adjusting
~~the a~~ distance between the cylindrical lens 250 and the photosensitive drum 106.

5 Therefore, like Embodiment 8, if ~~it is configured so that~~ the length of the
light emitting element 8 is as long as possible in the ~~sub-sub-scanning~~ direction,
and the cylindrical lens 250 is adjusted in terms of the radius of curvature and
the refractive index, and the distance between the cylindrical lens 250 and the
photosensitive drum 106 is adjusted, ~~whereby it is possible to obtain the light~~
10 with ~~the a~~ high luminous flux density and with the length of the section that is
the same ~~as in~~ the main scanning direction ~~and as in~~ the ~~sub-sub-scanning~~
direction. However, if the light ~~are is~~ condensed in the ~~sub-sub-scanning~~
direction only, the focal length of light becomes short only in the ~~sub-~~
~~sub-scanning~~ direction, and a difference occurs between the focal length of the
15 ~~sub-sub-scanning~~ direction and the focal length of the main scanning direction.
Accordingly, when the ~~sub-sub-scanning~~ direction of the light emitting element
8 is much longer than the main scanning direction, the focal length of the ~~sub-~~
~~sub-scanning~~ direction has a large difference from the focal length of the main
scanning direction. And then, it is not possible to obtain a clear latent image
20 on the photosensitive drum 106.

~~Besides~~Additionally, the description ~~in of~~ Embodiment 9 relates to ~~the a~~
case where the convex cylindrical lens 250 is used as the condensing
~~means structure.~~ ~~But, however,~~ instead of the convex cylindrical lens 250, ~~the a~~
micro lens ally 260 may be used as the condensing ~~means structure~~.

25 The micro lens ally 260 as the condensing ~~means structure~~ is formed as

shown in Fig. 30 so that the micro lenses may be arranged in a line in the main scanning direction, ~~the wherein a~~ shape of each micro lens is ~~a~~-oval of which a long axis is in parallel with the ~~sub-sub~~ scanning direction. ~~The A~~ purpose of forming such oval is to narrow ~~the~~ light down ~~to in~~ the ~~sub-sub~~ scanning direction.

The cylindrical lens 250 or the micro lens alley 260 is disposed between the light transmitting ~~means-structure~~ 310 and the photosensitive drum 106 as shown in Fig. 29 and Fig. 30; however, the light transmitting ~~means-structure~~ 310 may be disposed just above the cylindrical lens 250 or the micro lens alley 260.

In addition, if the light transmitting ~~means-structure~~ 310 is composed of ~~the an~~ image transmitting type of lens, the light transmitting ~~means-structure~~ 310 may be disposed just above the cylindrical lens 250 or the micro lens ally 260.

Embodiment 10

In Embodiments 5 through 9, respective layers are formed in the order, the transparent electrode element 1, the organic EL layer 4, and the metal electrode layer 5. Therefore, ~~the~~ light emitted from the light emitting element 8 is discharged to the side of the transparent substrate 301 as shown in Fig. 16.

But, the light source 200 may emit ~~the~~ light to another side opposite to the direction described in Embodiments 5 through 9, that is to say, the light may be emitted upwardly as shown in Fig. 16.

Since the light emitting element 8 is provided with the opaque metal electrode layer 5 on the upper side as described in Embodiments 5 through 9,

the light cannot be emitted upwardly. As described in Embodiment 4, in order to improve the light emitting efficiency of the organic EL layer, the cathode must use ~~the~~ be of a material of which whose work function is lower than the transparent electrode element 1 that is to be the anode, and the opaque metal electrode layer 5 is used as the cathode.

Now, in order to emit ~~the~~ light upwardly, the metal electrode layer 5 is formed so as to have a thickness (about 100Å) as far as the light is transmitted. Thereby, the light can be emitted upwardly. But, the light is allowed to be discarded downwardly, too. To avoid the light from discharging downwardly, ~~the~~ reflection material 404 is provided between the transparent substrate 301 and the transparent electrode element 1.

Besides, like Embodiment 4, ~~the~~ electrode layer 5a is formed on ~~the~~ metal electrode layer 5 so as to flow ~~the~~ an electric current uniformly on ~~the~~ thin metal electrode layer 5. ~~And a~~ Also in this embodiment, ~~the~~ organic EL layer 4, the metal electrode layer 5 and the electrode layer 5a are covered with ~~the~~ resin 6 and ~~the~~ sealing glass 7 for the protection of the organic EL layer 4.

As described above, ~~the~~ small projection 202d or ~~the~~ light guide 402 is formed on the electrode layer 5a, and the sealing glass 7 covers ~~the~~ light emitting element 8 and the small projection 202d, or the light guide 402, which are shown in Fig. 32A and Fig. 32B.

Embodiment 11

~~The~~ Light source 200 in this embodiment as shown in Fig. 33 is composed of ~~the~~ light transmitting ~~means~~ structure 310 and ~~the~~ light emitting element 8. The light transmitting ~~means~~ structure 310 is for exactly forming

~~the a~~ latent image on the photosensitive drum 106 as described above. The light emitting element 8 is configured by a flat luminous layer. ~~The e~~Organic electro luminescence (which is called ~~the organic EL~~) material is applied to an example of the flat luminous layer.

5 Additionally, one of ~~the~~ light emitting elements 8 is provided on the light transmitting ~~means-structure~~ 310 so as to correspond to one of ~~the~~ fiber lenses 313 (which is called a single lens 313) composing the fiber lens alley shown in Fig. 6A. ~~The l~~Light from the light emitting element 8 illuminates the photosensitive drum 106 through ~~the a~~ corresponding single lens 313, and then
10 ~~the a~~ latent image is formed thereon.

Next, the light emitting element 8 is formed directly on the light transmitting ~~means-structure~~ 310, of which a production method is described hereinafter.

~~The t~~Transparent electrode layer 2, such as ~~the an~~ ITO electrode to be ~~the~~ material of ~~the~~ transparent electrode element 1, is formed on ~~whole entire~~ opening surfaces (~~the~~ sectional surfaces of ~~the~~ single lenses 313) of the light transmitting ~~means-structure~~ 310 by ~~the~~ evaporation or ~~the~~ application as shown in Fig. 34. Thereby, the transparent electrode layer 2 is attached tightly to the light transmitting ~~means-structure~~ 310 ~~in-optically~~.
15

20 And then, ~~the an~~ upper section of each single lens 313 in this embodiment, from which the light transmitting ~~means-structure~~ emits ~~the a~~ ray of light, is masked with ~~the~~ shading film 3 regarding this section only. And ~~the an~~ opening surface is subjected to ~~the~~ photolithography like ~~the~~ exposure and ~~the~~ development, or ~~the~~ etching, that is, ~~the~~ patterning. The patterning
25 removes the transparent electrode layer 2 on ~~the~~ parts without masking, while

~~the a~~ masked section becomes the transparent electrode element 1.

Next, ~~the~~ organic EL layer 4 is formed by applying the organic EL material on the ~~whole entire~~ surface of the opening surface on which the transparent electrode element 1 is formed, and then, the metal electrode layer 5 is formed on ~~the an~~ upper surface on the organic EL layer 4 as a common electrode. The organic EL layer 4 sandwiched between the transparent electrode element 1 and the metal electrode layer 5 becomes ~~the a~~ light emitting element.

~~Besides~~Additionally, the light emitting element 8 is subjected to the sealing as follows. ~~The r~~Resin 6 is applied on the sealing section 304 surrounding the single lens 313, and ~~in the last place~~as a final operation the metal electrode layer 5 on the opening surface and the resin 6 applied on ~~the a~~ periphery thereof are covered with ~~the an~~ approximately U-shaped sealing glass 7. ~~In As a~~ result, the light source 200 is completed.

According to the above steps, the light source 200 is formed combining the light transmitting ~~means-structure~~ 310 with the light emitting element 8 ~~in~~ optically in one piece. In ~~this~~ this formed light source 200, the organic EL layer 4 between the transparent electrode element 1 and the metal electrode layer 5 emits ~~the a~~ ray when ~~the an~~ electric field is applied ~~on to~~ the transparent electrode element 1 and the electrode layer 5.

Since the light emitting element 8 using the organic EL material is formed directly on the light transmitting ~~means-structure~~ 310, ~~the~~ light emitted from the light emitting element 8 is transmitted directly to the light transmitting ~~means-structure~~ 310 without passing through ~~the a~~ low refractive index layer with ~~the~~ low directivity. Accordingly, the light can reach the

photosensitive drum 106 ~~keeping the~~ while maintaining sufficient luminous intensity and no total reflection. Therefore, it is possible to form a latent image with high resolution without shortening ~~the a~~ luminescence life of the light emitting element 8 and without ~~the a~~ short focal depth due to ~~the a~~ large angle aperture. In other words, since there is no total reflection of the light in the light source in this embodiment, when a specific latent image is formed, the electric power consumption of this light source can be reduced more than ~~the~~ electric power consumption of ~~the a~~ light source wherein ~~the~~ light goes through ~~the a~~ low refractive index layer with ~~the~~ low directivity.

Embodiment 12

Fig. 35 shows ~~the~~ light transmitting ~~means~~ structure 310 composing the light source 200, in which each single lens 313 has a diameter smaller than ~~the a~~ length and breadth of ~~the~~ light emitting element 8, and ~~the a~~ configuration is explained hereinafter.

The light source 200 shown in Fig. 35, wherein ~~the~~ light emitting elements 8 are disposed on the light transmitting ~~means~~ structure 310, ~~applies~~ employs the single lens 313 of which the diameter is smaller than the length and breadth of the light emitting element 8. That is to say, one of the light emitting elements 8 corresponds to a plurality of single lenses 313.

Regarding the single lens 313, as ~~the a~~ specific number of single lenses is one unit, a plurality of single lenses 313 ~~are~~ is placed within ~~the a~~ space surrounded by ~~the~~ light absorbing layers 312 and ~~the~~ base frames 311 as shown in Fig. 6B, or placed in the same way after ~~the~~ light absorbing layer 312 is provided on ~~the a~~ ~~periphery~~ peripheral portion of each single lens 313.

The light emitting element 8 may be formed on ~~thus~~this configured light transmitting ~~means-structure~~ 310, of which ~~a producing-production~~ method is the same as in Embodiment 11. The diameter of the single lens 313 is smaller than the light emitting element 8 under such configuration, so that the light emitting element 8 can be formed regardless of ~~the~~a delicate positioning relationship between the light emitting element 8 and the single lens 313. ~~In~~ From this point of view, the light source 200 can be formed simply more than the aforementioned light source 200 that applies the light transmitting ~~means-structure~~ 310 described in Embodiment 1.

Embodiment 13

Consequently, here is explained about ~~the~~ light source 200 that is provided with ~~the~~ directivity ~~means-structure~~ between ~~the~~ light emitting element 8 and the light transmitting ~~means-structure~~ 310 for steering ~~the~~an advancing direction of ~~each~~ light emitted from the light emitting element 8 to a predetermined direction, and that is configured by forming the light transmitting ~~means-structure~~ 310, ~~and~~ the directivity ~~means-structure~~ and the light emitting element 8 in one piece.

The directivity ~~means-structure~~ is for leading more light into the light transmitting ~~means-structure~~ 310 by correcting the advancing direction of ~~each~~ light. The directivity ~~means-structure~~ in Embodiment 13 is provided with ~~the~~a mesa structure (mesa sheet), which is explained here. The mesa structure is for correcting a light direction to a predetermined direction by reflecting ~~the~~ incident light, and is configured in a form of a polygonal frustum of a pyramid wherein the light emitting element 8 is disposed on ~~the~~a side of ~~the~~an upper

surface as shown in Fig. 36B. Specifically, ~~a-directivity means-structure 701~~ without the mesa structure shown in Fig. 36A allows ~~the-side surface 701a of the~~ directivity ~~means-structure 701~~ to transmit parts of or most of ~~the-light emitted~~ from the light emitting element 8 at a specific incident angle θ , 702, so that ~~the~~
 5 ~~a volume of the-light incident into the-bottom 706 could decrease. And, the-a~~ transmission efficiency could ~~come-down~~ be reduced. On the contrary, ~~a-~~ directivity ~~means-structure 701~~ with the mesa structure ~~in-of~~ Fig. 36B increases ~~the-a~~ possibility that ~~the-light emitted from the light emitting element 8 at a~~ specific incident angle θ , 702, ~~are-is~~ reflected on the side surface 701a of the
 10 directivity ~~means-structure 701~~, so that ~~the-a~~ volume of the light to reach the base surface 706 could increase. ~~In-As a~~ result, it is possible to improve ~~the-~~ transmission efficiency. ~~Besides~~ Additionally, Fig. 36A and Fig. 36B show a comparison with the same ray of light emitted from the light emitting element 8.

Then, the following is concerned with ~~the-a~~ method of producing the light
 15 source combined optically with the directivity ~~means-structure 701~~ including the mesa structure.

~~The-A~~ directivity imparting layer 801 is formed on ~~the-light transmitting~~ ~~means-structure 310~~ as described in Embodiments 11 and 12, as shown in Fig. 37(A). ~~The-This~~ forming is ~~carried-out~~ performed by applying or evaporating a
 20 material to be the directivity imparting layer ~~thereon~~ onto the light transmitting structure. On the directivity imparting layer 801, ~~the-transparent electrode~~ layer 2 is applied or evaporated in the same way. ~~Besides~~ Additionally, the directivity imparting layer 801 is made of a material such as ~~Acrylic-acrylic~~ and ~~Polyarylatepolyarylate~~, for example.

25 After the directivity imparting layer 801 and the transparent electrode

layer 2 are formed on the light transmitting ~~means-structure~~ 310, ~~the~~-etching is performed for forming ~~the-a~~ small projection as described in Embodiment 5.

According to these steps, ~~the-a~~ directivity imparting ~~means-structure~~ 801 with ~~the-a~~ mesa structure and the transparent electrode element 1 are formed

5 simultaneously as shown in Fig. 37(B).

Next, on the transparent electrode element 1 shown in Fig. 37(B), ~~the-~~ organic EL material to be the light emitting element 8 is evaporated, and then ~~the-metal~~ to be the metal electrode layer 5 is evaporated thereon.

Now, the directivity ~~means-structure~~ 701 is thicker than the transparent
10 electrode element 1, the light emitting element 8, or the metal electrode layer 5.

And, there are sections 808 without an upper surface ~~of-corresponding to the~~ directivity ~~means-structure~~ 701 between the transparent electrode elements 1.

When the organic EL material and the metal are evaporated on ~~the-whole~~an entire surface of the light transmitting ~~means-structure~~ 310 on which the
15 directivity ~~means-structure~~ 701 with mesa structure and the transparent electrode element 1 ~~are~~-formed after ~~the~~-etching for obtaining the mesa structure, the organic EL material and ~~the-metal~~ evaporated on the section 808 flow down along ~~the-side~~ surface 701a of the directivity ~~means-structure~~ 701 and collect at ~~the-a~~ lower end part of the directivity ~~means-structure~~ 701.

20 Accordingly, the organic EL material and the metal evaporated on each transparent electrode element 1 are separated from the organic EL material and ~~the-metal~~ evaporated on the-other transparent electrode elements 1.

Therefore, even if only each upper surface of the transparent electrode element 1 is not evaporated with the organic EL material and the metal, when
25 the organic EL material and the metal are evaporated on the ~~whole-entire~~

surface of the light transmitting ~~means-structure~~ 301, the light emitting element 8 and the metal electrode layer 5 are formed on each directivity ~~means-structure~~ 701. When the light emitting element 8 and the metal electrode layer 5 are formed by evaporating the organic EL material and the metal on the ~~whole~~ entire surface of the light transmitting ~~means-structure~~ 301, the ~~masking~~ is not required for ~~the~~ evaporation of the light emitting element 8 and the metal electrode layer 5. However, when the metal electrode layer 5 and the transparent electrode ~~layer-element~~ 1 are short-circuited, the light emitting element 8 does not emit ~~the~~ light. Accordingly, the metal electrode layer 5 may be formed by evaporating ~~the~~ metal on only the upper surface of the light emitting element 8.

As described above, since the light transmitting ~~means~~structure, the directivity ~~means~~structure, and the light emitting layer are combined in one piece, a layer that has ~~the~~ low directivity with ~~the~~ a low refractive index does not exist between layers. According to such configuration, ~~the~~ light from the light emitting element is transmitted directly to the light transmitting ~~means-structure~~ without passing through ~~the~~ a low directivity layer. Therefore, most of the light can reach the photosensitive drum ~~keeping the~~ while maintaining sufficient luminous intensity without leakage as described above. In addition, the directivity ~~means-structure~~ in this embodiment steers (corrects) ~~the~~ light from the light emitting element to a specific degree, and this makes it possible to let most of the light from the light emitting element reach the light transmitting ~~means~~structure. Moreover, ~~the~~ light that has reached the light transmitting ~~means-structure~~ keeps maintains the luminous intensity higher than that in Embodiments 11 and 12 because there is no layer without ~~the~~

directivity.

Besides Additionally, when ~~the a~~ light source is provided with the directivity ~~means structure~~ having the mesa structure, ~~the a~~ light transmission efficiency between the organic EL layer and the photosensitive drum could be improved a-four times as high as ~~the a~~ light source without the directivity ~~means structure~~.

It is not surprising that, if the directivity ~~means structure~~ is used, ~~the a~~ size of ~~the an~~ angle aperture ~~is does~~ not need to be large to improve the light transmission efficiency. And, ~~the a~~ focal depth of the light transmitting ~~means structure~~ remains ~~in~~ deep. It is needless to say that the light source can form a latent image on the photosensitive drum exactly.

In the above description, the light source 200 of the image writing apparatus in this invention is applied to the color laser printer 100 of ~~the a~~ tandem type. The light source of the image writing apparatus in this invention can be applied to ~~the a~~ color laser printer except for the tandem type or ~~the a~~ laser printer for ~~the~~ monochrome printing.

Industrial Applicability

Since the present invention can convert ~~the an~~ advancing direction of ~~the~~ light emitted from ~~the a~~ light source of ~~the an~~ image writing apparatus, it is not necessary to pay any attention to ~~the a~~ direction ~~to place of placing~~ the light source and ~~the a~~ direction of the emitted light. Therefore, the image writing apparatus of this invention can downsize ~~the a~~ printer by disposing the light source to face ~~the a~~ direction ~~that the in which a sub-sub~~ scanning direction ~~dimension gets is~~ short.

In addition, the light source of the image writing apparatus is provided with ~~the~~ directivity ~~means~~ structure for imparting ~~the~~ directivity to ~~the~~ light emitted from ~~the~~ a light emitting element, whereby most of ~~the~~ light can be transmitted to the photosensitive drum through ~~the~~ light transmitting ~~means~~ structure without making ~~the~~ an angle aperture of the light transmitting ~~means~~ structure large. Accordingly, while ~~keeping~~ the maintaining a focal depth of the light transmitting ~~means~~ structure deep, it is possible to improve ~~the~~ light transmission efficiency between the light emitting element and the photosensitive drum, and to increase ~~the~~ luminous intensity on the photosensitive drum. In ~~As~~ a result, the light source of the image writing apparatus in this invention can be utilized as the light source to form a clear latent image on the photosensitive drum.

Moreover, since ~~the~~ light emitted from ~~the~~ a light emitting element with a large luminous area ~~are~~ is condensed through ~~the~~ a condensing ~~means~~ structure, it is possible to obtain ~~the~~ light with high luminous flux density by the condensing ~~means~~ structure. Since the light source is provided with the condensing ~~means~~ structure and ~~the~~ a light emitting element extended ~~to~~ in ~~the~~ a sub-sub-scanning direction, ~~the~~ light emitted from the light emitting element can be condensed ~~to~~ in the sub-sub-scanning direction, and ~~the~~ light with high luminous flux density can be obtained at short intervals in ~~the~~ a main scanning direction. Therefore, the light source of the image writing ~~means~~ apparatus in this invention is available for ~~the~~ a light source to form ~~the~~ a latent image with high resolution on ~~the~~ a photosensitive drum.

Further-more, since ~~the~~ light transmitting ~~means~~ structure, ~~the~~ directivity ~~means~~ structure, and ~~the~~ a light emitting layer are combined in one

piece, a layer that has a low directivity with a low refractive index does not exist between layers. According to such configuration, ~~the~~ light from ~~the~~ a light emitting element is transmitted directly to ~~the~~ light transmitting ~~means~~ structure without passing through ~~the~~ a layer with low directivity. Therefore,

5 the light source of the image writing apparatus in this invention is available for ~~the~~ a light source wherein most of ~~the~~ light can reach ~~the~~ a photosensitive drum ~~keeping the while maintaining~~ sufficient luminous intensity almost without total reflection.

Abstract of the Disclosure

An image forming apparatus includes a light source provided with a-
converting ~~means-structure~~ for converting ~~the-an~~ an advancing direction of light
5 emitted from the light source, whereby ~~the-a~~ a direction in which the light source
is disposed can be determined regardless of a direction in which light is emitted.
The advancing direction of the light emitted from a light emitting element is
converted into a direction in which ~~the-light transmitting means-structure~~ can
transmit the light, so that ~~the-a~~ a luminous intensity on ~~the-a~~ a photosensitive
10 drum can be increased. ~~It-~~ The light source is designed so as to increase a light
emitting area of the light emitting element and condense ~~the-light~~ light emitted
therefrom, ~~in result the luminous flux density can be improved.~~ The light
emitting element ~~applies-~~ utilizes a flat luminous unit, which is combined with a
light transmitting ~~means-structure~~ in one optical piece.